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Amorphous $\text{SiO}_x\text{C}_y(\text{:Er})$ films deposited by RF-magnetron sputtering on $\text{ZrB}_2\text{--SiC}$ ceramics: antioxidation and strengthening effects

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Abstract

The effect of amorphous $\text{a-SiO}_x\text{C}_y(\text{:Er})$ layers on the oxidation behavior of $\text{ZrB}_2\text{--SiC}$ composite ceramics has been studied. $\text{ZrB}_2\text{--}15\%\text{SiC}$ composite samples were obtained by hot pressing of $\text{ZrB}_2+15\%\text{SiC}$ powder at 1850°C and 48 MPa. Amorphous $\text{a-SiO}_x\text{C}_y(\text{:Er})$ thin films (1 μm thick) were deposited on $\text{ZrB}_2\text{--SiC}$ specimens at a temperature of 200°C by reactive RF-magnetron sputtering of SiC/Er target in argon/oxygen flow. Coated $\text{ZrB}_2\text{--SiC}$ samples were exposed to a high-temperature oxidation at 1400°C for 1 hour at atmospheric pressure. Structure and phase composition were examined by optical microscopy, X-ray diffraction, SEM and EDS. It was demonstrated that $\text{a-SiO}_x\text{C}_y$ coating noticeably enhances the oxidation resistance of the surface. Further development of the oxidation resistance was observed in Er-incorporated $\text{a-SiO}_x\text{C}_y$ coating. Along with the improvement of the antioxidation resistance the deposition of $\text{a-SiO}_x\text{C}_y(\text{:Er})$ coatings resulted in increasing of bending strength of $\text{ZrB}_2\text{--SiC}$ samples in comparison to uncoated samples. The enhancement of surface stability and strengthening by a thin $\text{a-SiO}_x\text{C}_y(\text{:Er})$ coating is discussed in terms of the effects of dense coating by itself and the modification of a surface silica layer by erbium incorporation as well.

Introduction

Thermal durability and antioxidation resistance at extreme temperatures are the main requirements for new materials working in extremely hot environment: ultrasonic vehicles, rocket nozzles, combustion chambers, turbine engines, etc. $\text{ZrB}_2\text{--SiC}$ composites are well known ultrahigh-temperature ceramics with high temperature stability, high thermal conductivity and oxidation resistance. Antioxidation properties of the $\text{ZrB}_2\text{--SiC}$ composites are commonly attributed to the formation of borosilicate surface layer that appears due to the oxidation of SiC

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